



AT/IDW

RESPONSE UNDER 37 C.F.R. § 1.116
EXPEDITED PROCEDURE
GROUP 1752
PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Docket No: Q80326

Kunihiko KODAMA

Appln. No.: 10/806,451

Group Art Unit: 1752

Confirmation No.: 1792

Examiner: Amanda C. Walke

Filed: March 23, 2004

For: POSITIVE RESIST COMPOSITION AND METHOD OF FORMING RESIST PATTERN
USING THE SAME

RESPONSE UNDER 37 C.F.R. § 1.116

MAIL STOP AF

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

This Response is to the Office Action mailed September 20, 2005.

Please consider the remarks as set forth on the following pages.

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